

Search Notes	Application/Control No.	Applicant(s)/Patent under Reexamination	
	10/738,411	MCKIE ET AL.	
	Examiner	Art Unit	
	Shengjun Wang	1617	

**SEARCHED**

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
CAPLUS, MEDLINE, BIOSIS, EMBASE	6/8/2007	SW
salicylic acid, chlorosalicylic acid, halogenated salicylic acid, acne, pore size, sebum, retinoid, phytol, finasteride.		
inventor search	6/8/2007	SW